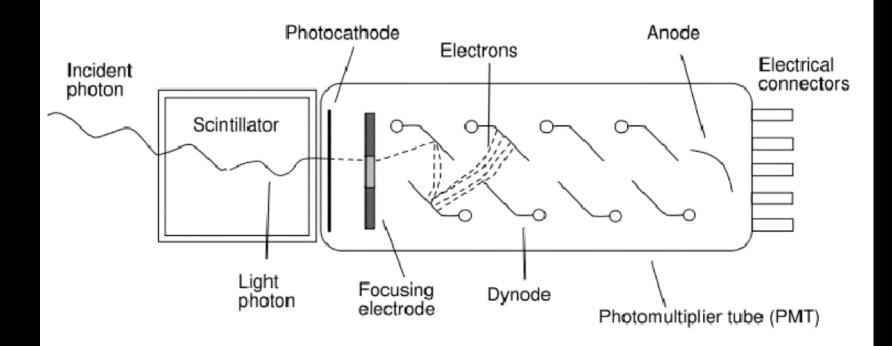
A new solid state tracking detector: Electron Emission Membranes and a MEMS made vacuum electron multiplier

only ideas: no data

Harry van der Graaf Nikhef, Amsterdam

TIPP 2011, Chicago, Il Saturday June 11, 2011 12:20 h [522]

A very successful photon detector: the Photomultiplier (1948)



- good quantum efficiency
- rather fast
- low noise
- little dark current, no bias current
- radiation hard
- quite linear

- voluminous & heavy
- no position resolution
- expensive
- quite radioactive
- can't stand B fields

Reduce size of dynodes (volume downscaling):

- keep potentials as they were $(V_{step} \sim 200 \text{ V})$
- (non relativistic) electron trajectories same form, but smaller (volume)
- multiplication yield: identical
- 1st dynode: focussing, yield
- pixel input source capacity: only ~ 10 fF
- required gain $\sim 1000 = 2.5^4 = :5$ dynodes sufficient

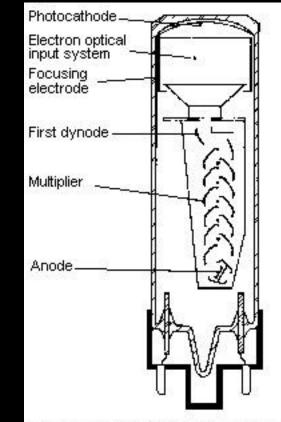
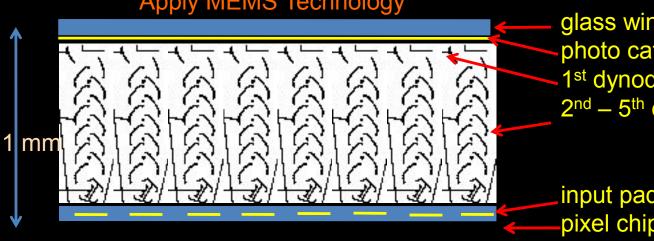


Fig. 8.1. Schematic diagram of a photomultiplier tube (from Schonkeren [9.1])



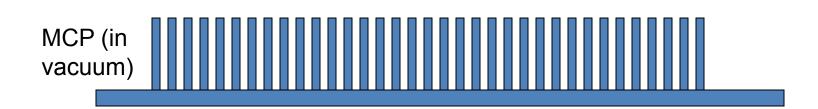
glass window photo cathode 1st dynode $2^{nd} - 5^{th}$ dynode

input pads pixel chip

VACUUM! No 'gas amplification'

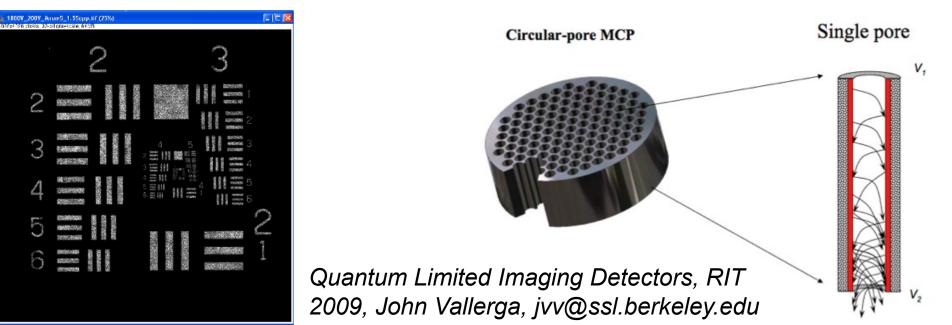
Apply MEMS Technology

Use a MicroChannelPlate MCP?



John Vallerga: TimePix + MCPs

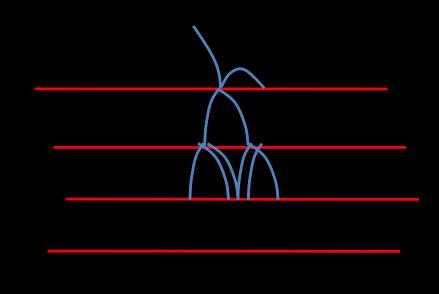
We do not know how to make MEMS made MCP. Problem: aspect ratio of holes



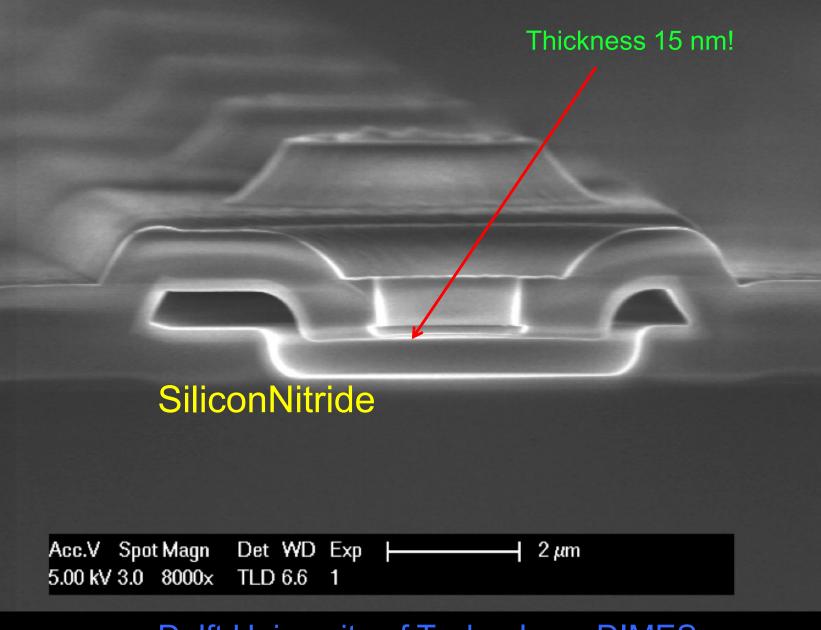
The transmission dynode: ultra thin (20 - 100 nm) layers

diamond SiNitride (Si $_3N_4$) Si doped (SiRichNitride, SRN) Csl doped SiO $_2$

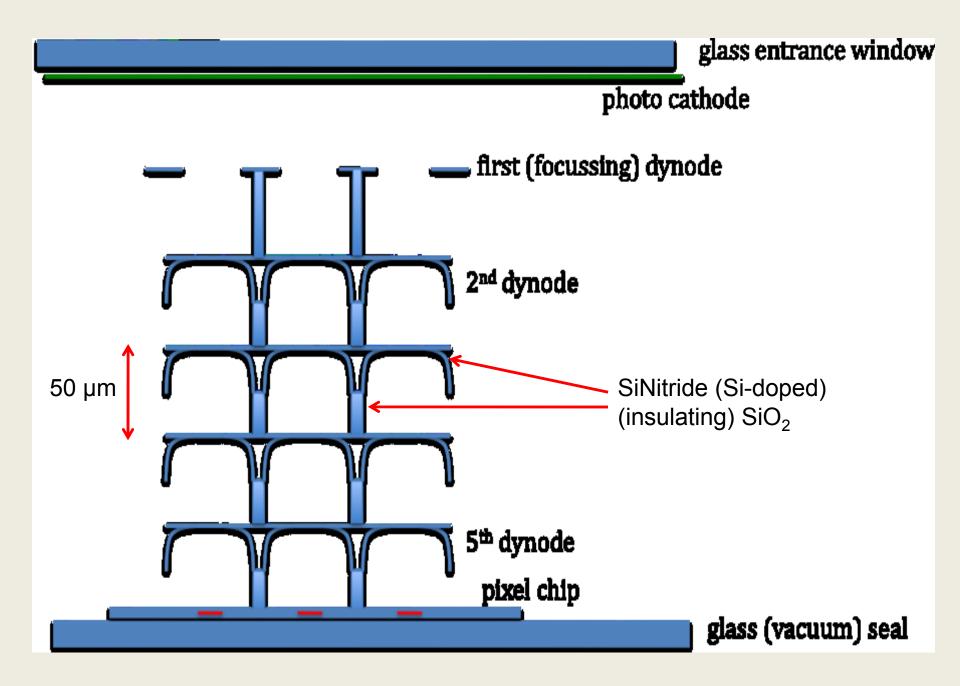


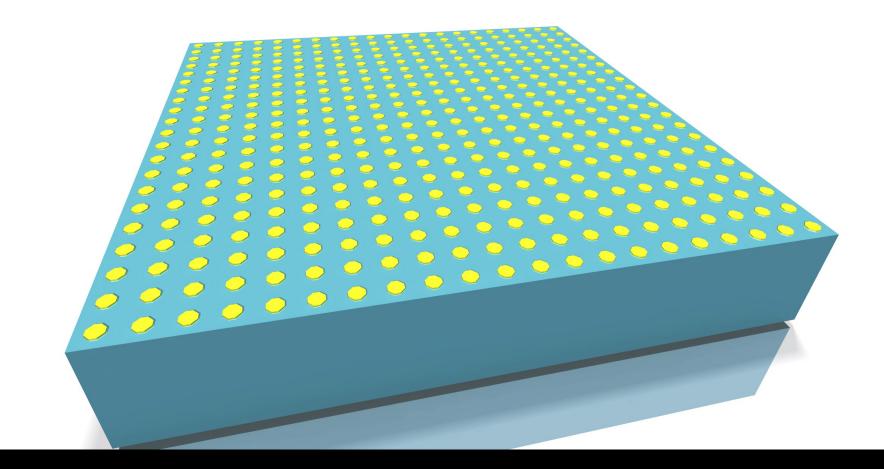


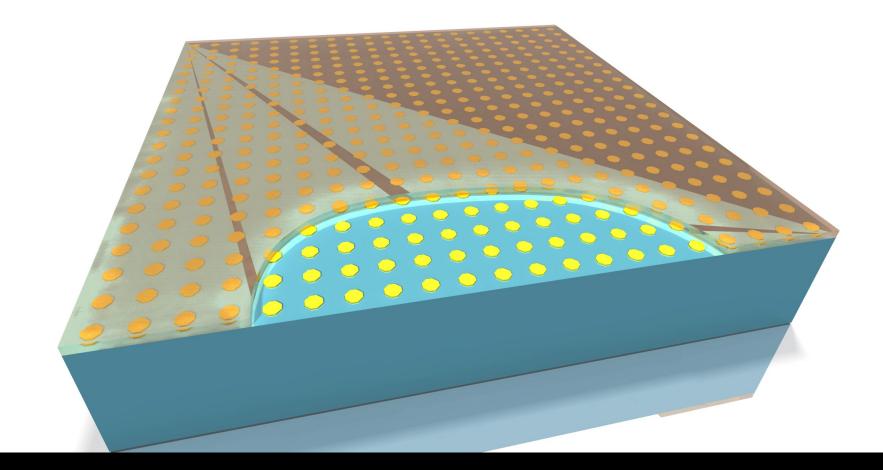
- ultra fast (single electron) detector: σ = 10 ps
- E-force much larger than Lorenz force: operates in B-field
- radiation hard
- low mass

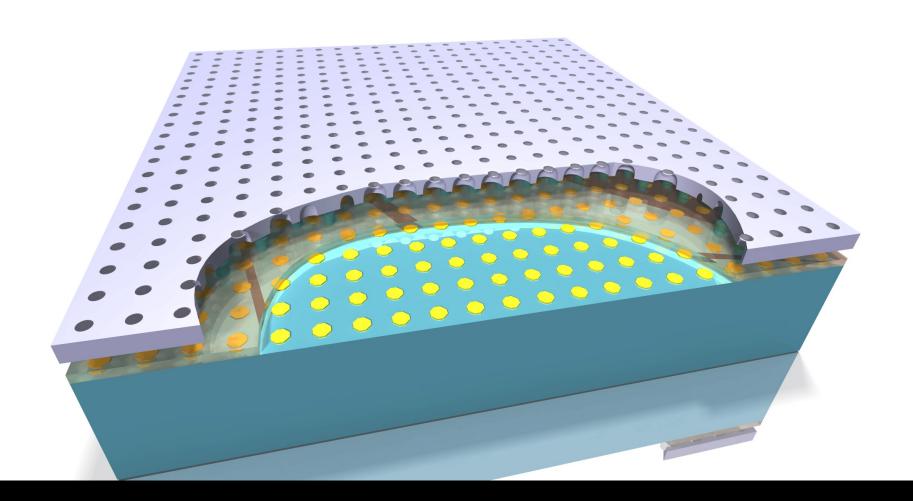


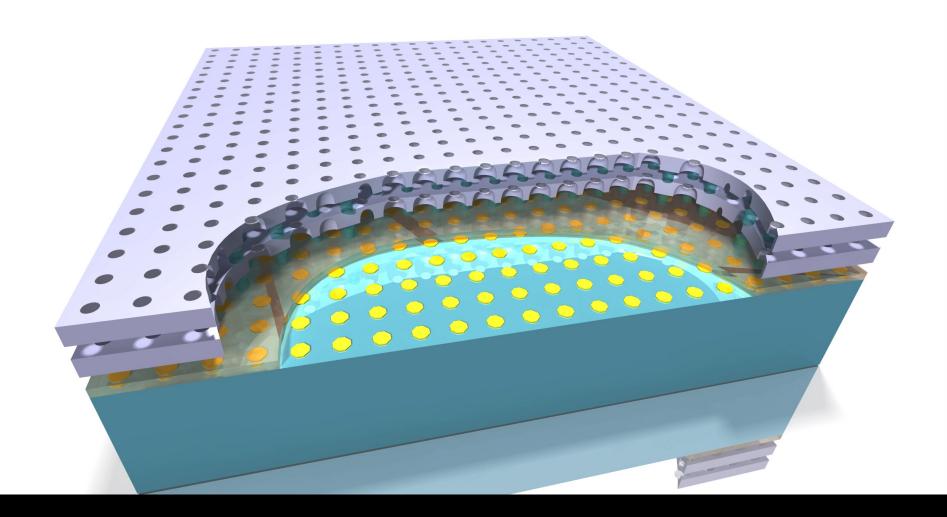
Delft University of Technology: DIMES

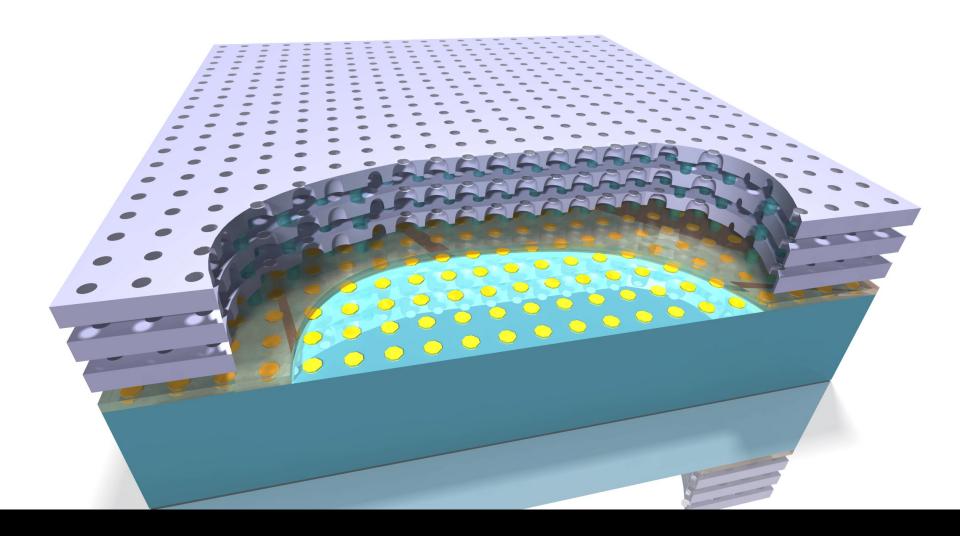


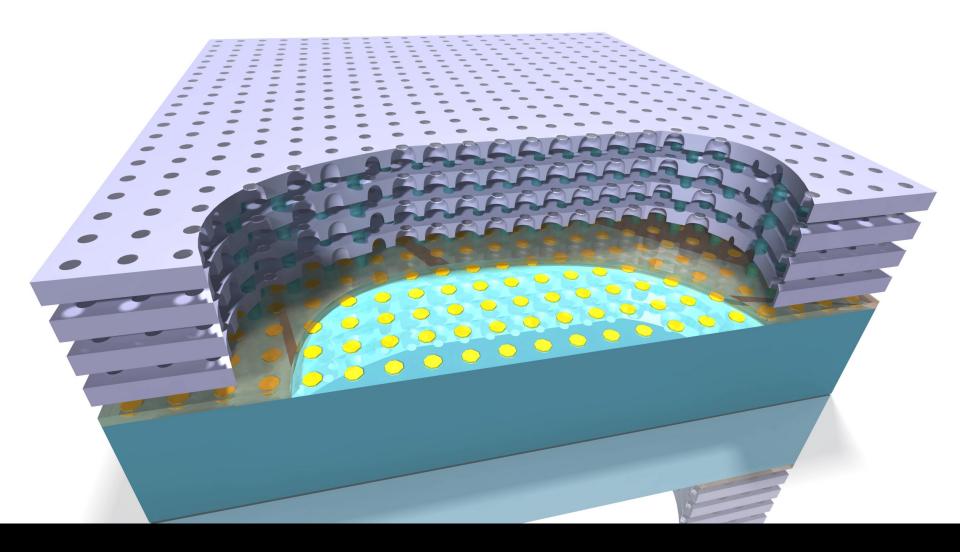


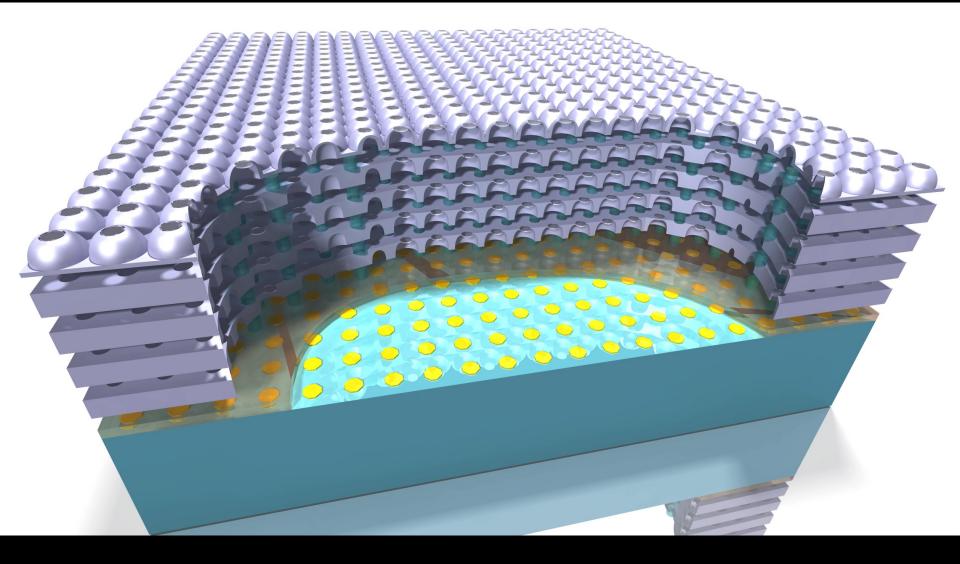


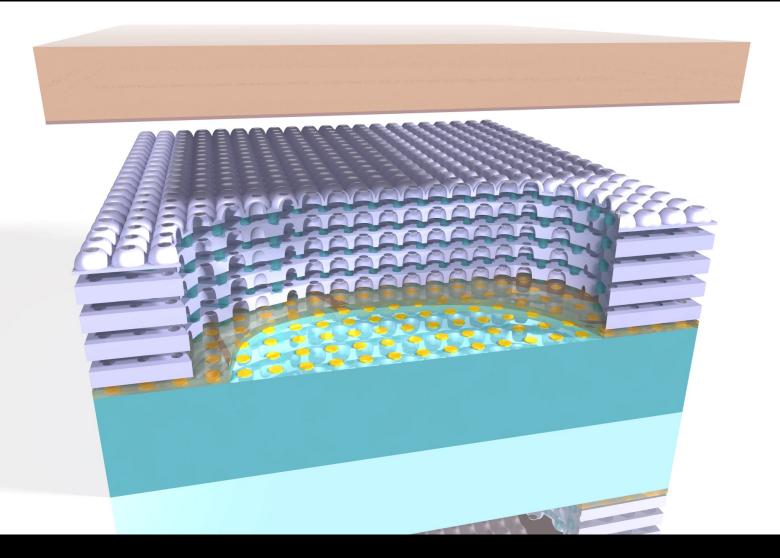


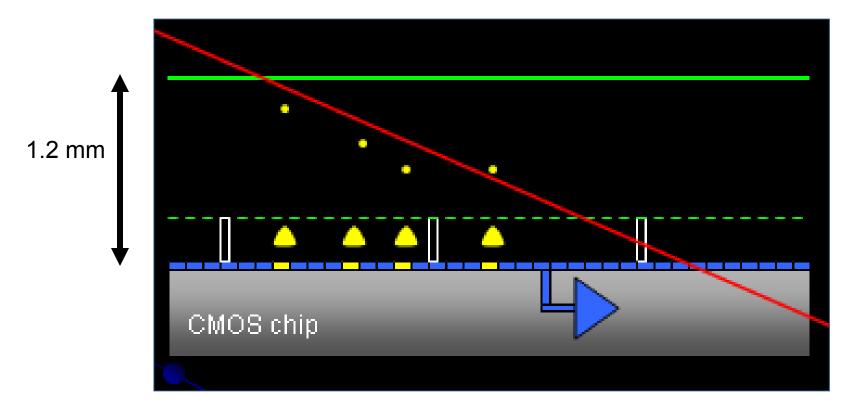




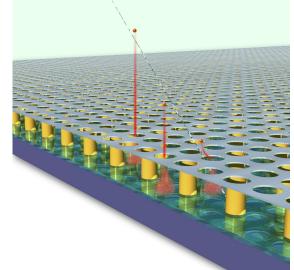


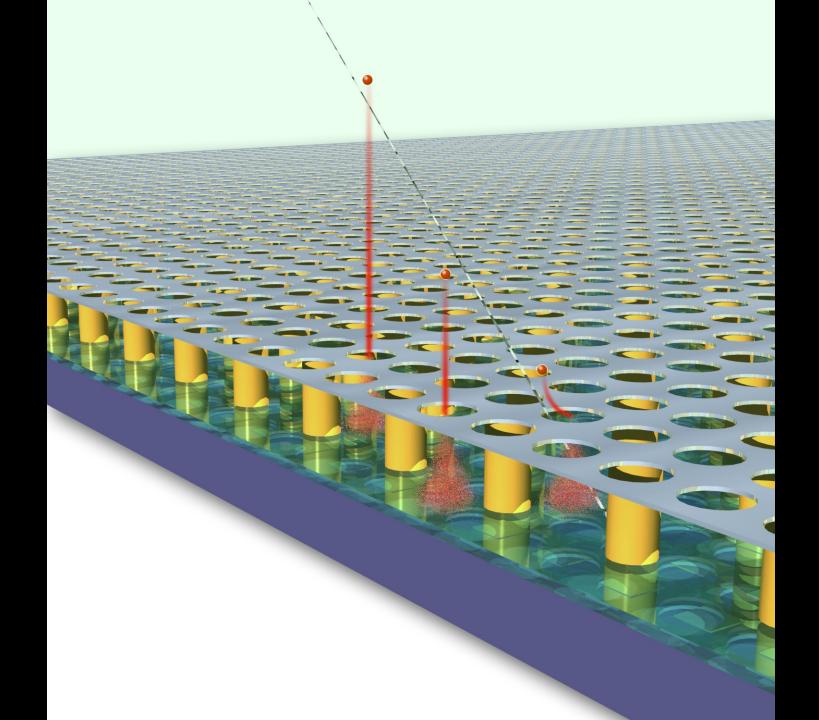




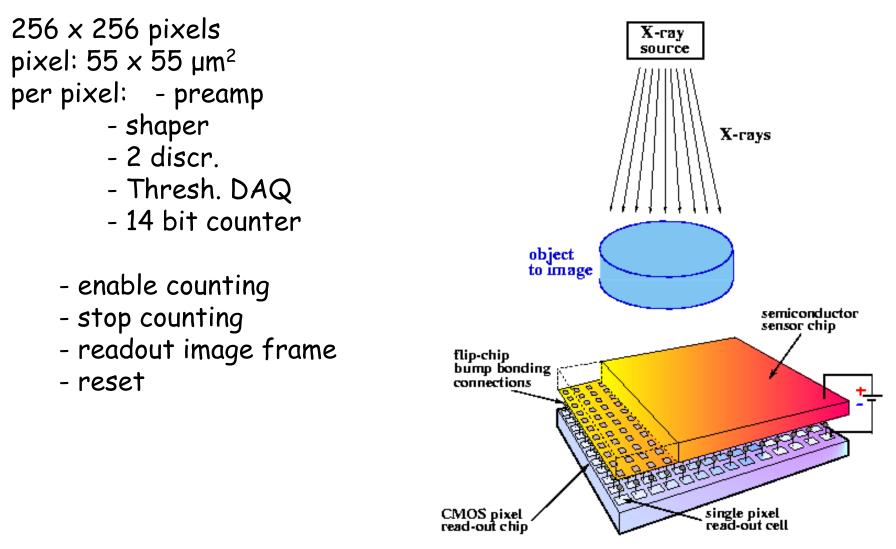


GridPix Gaseous Detector: a readout of Time Projection Chambers



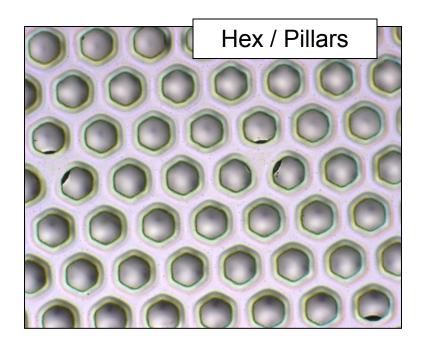


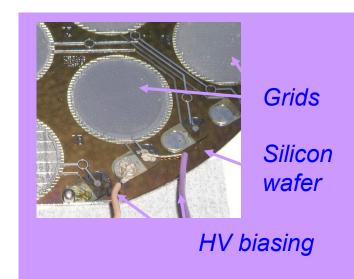
The MediPix2 pixel CMOS chip



We apply the 'naked' MediPix2 chip without X-ray convertor!

Wafer post-processing:InGrid



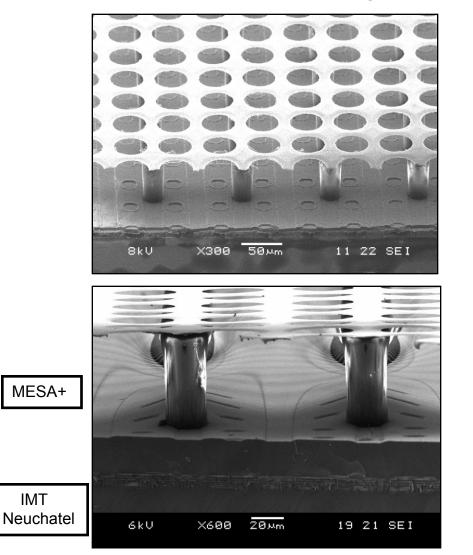


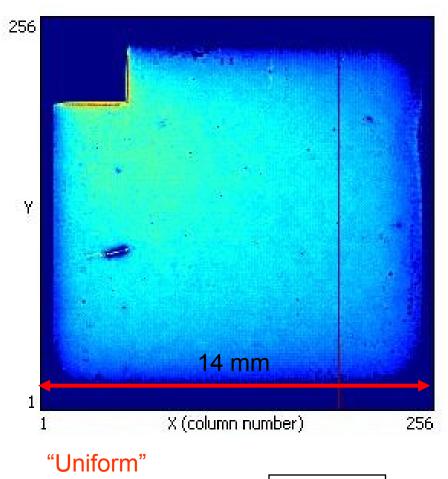
InGrid: an Integrated Grid on Si (wafers or chips)

- perfect alignment of grid holes and pixel pads
- small pillars Ø, hidden pillars, full pixel area coverage
- Sub-micron precision: homogeneity
- Monolithic readout device: integrated electron amplifier

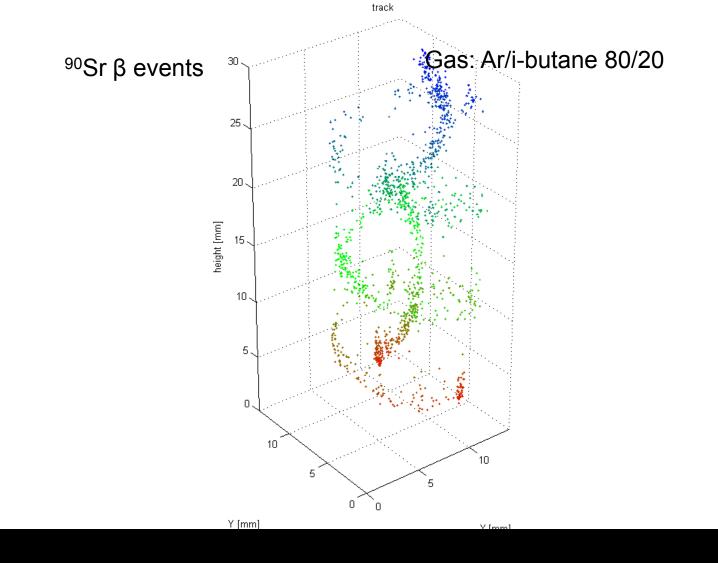
Full post-processing of a TimePix

• Timepix chip + SiProt + Ingrid:

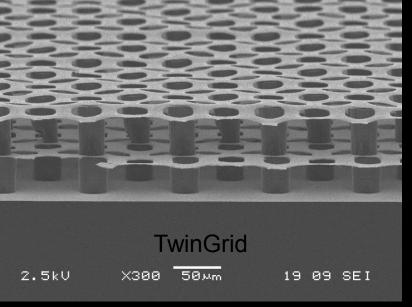


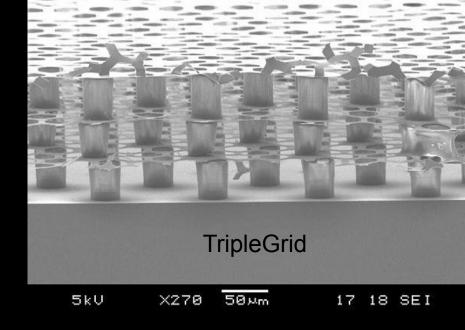


Charge mode

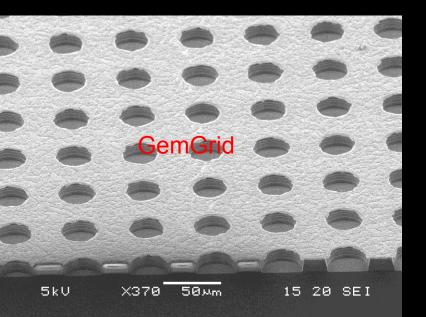


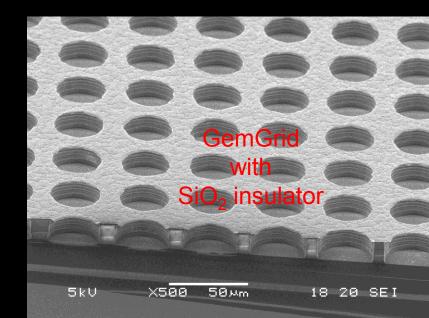
Efficiency to detect single electrons > 95 %

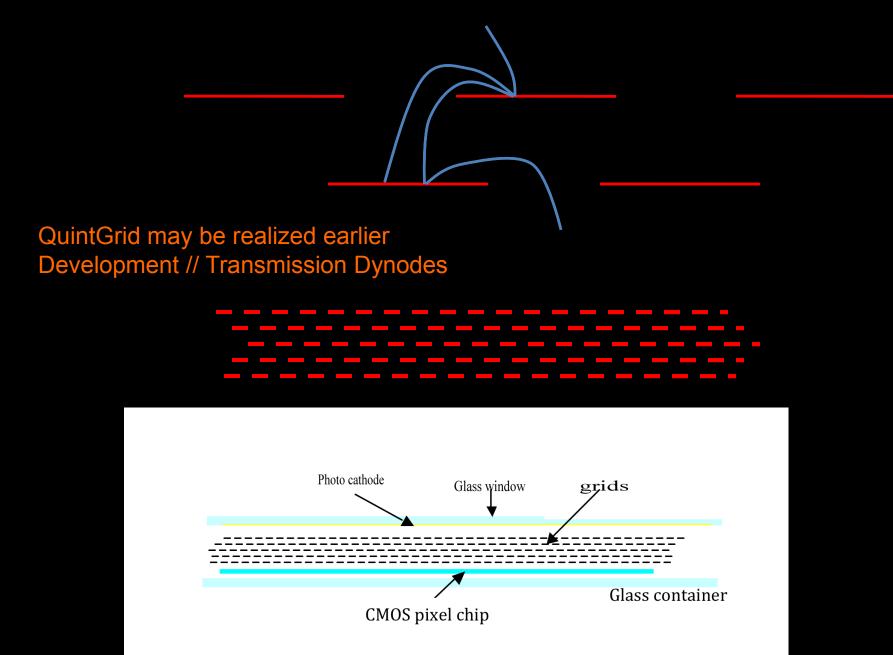


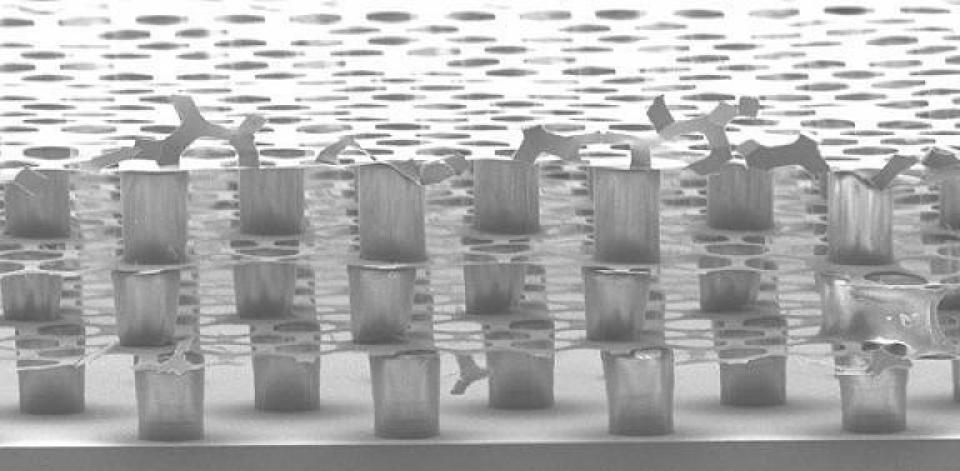


Development of MEMS technology Wafer Post Processing 'There is plenty of room at the top' supported by Dutch Economical Affairs









We can make TripleGrids!





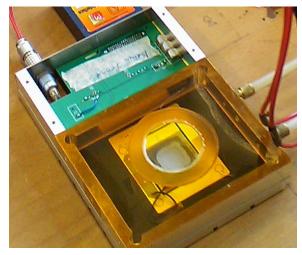


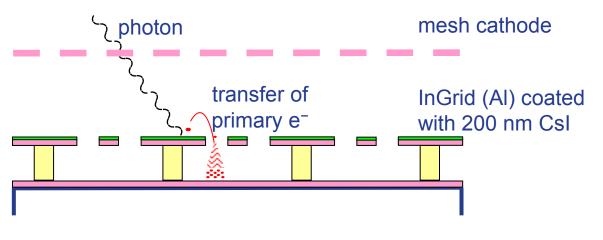
17 18 SEI

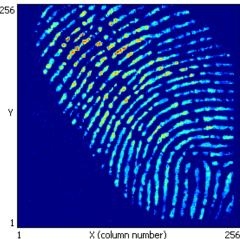
Photosensitive GridPix

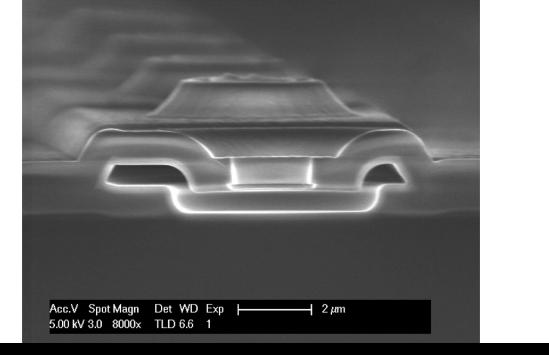
Univ. Twente and Weizmann institute InGrid with CsI on alu. anode Detect by means of gasgain Better anode readout \rightarrow TimePix

UV light 200-400 nm First test, InGrid without CsI UV well absorbed by my fingerprint





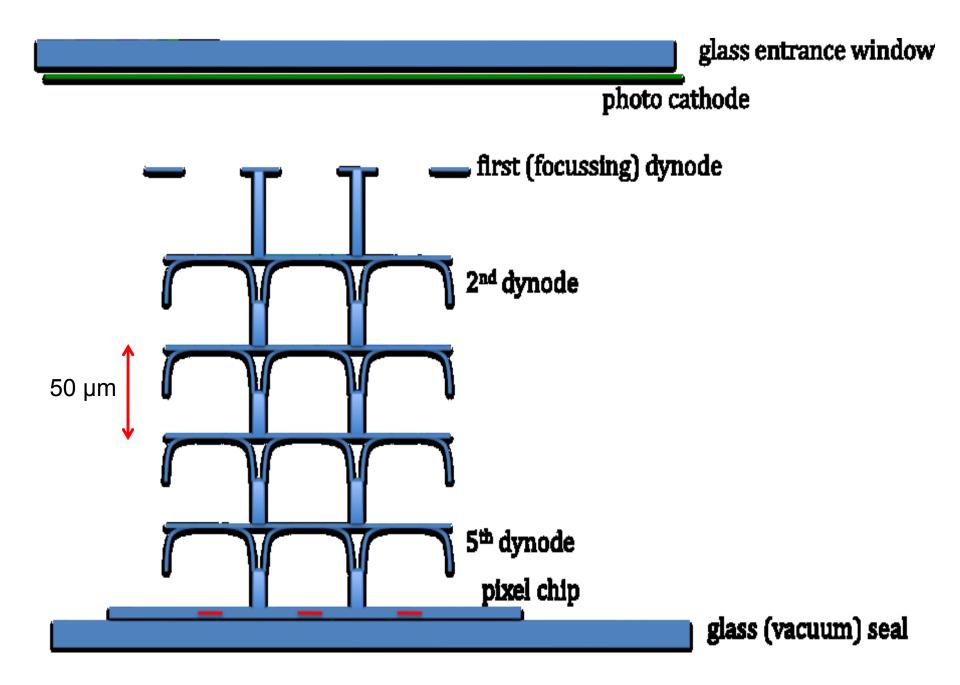


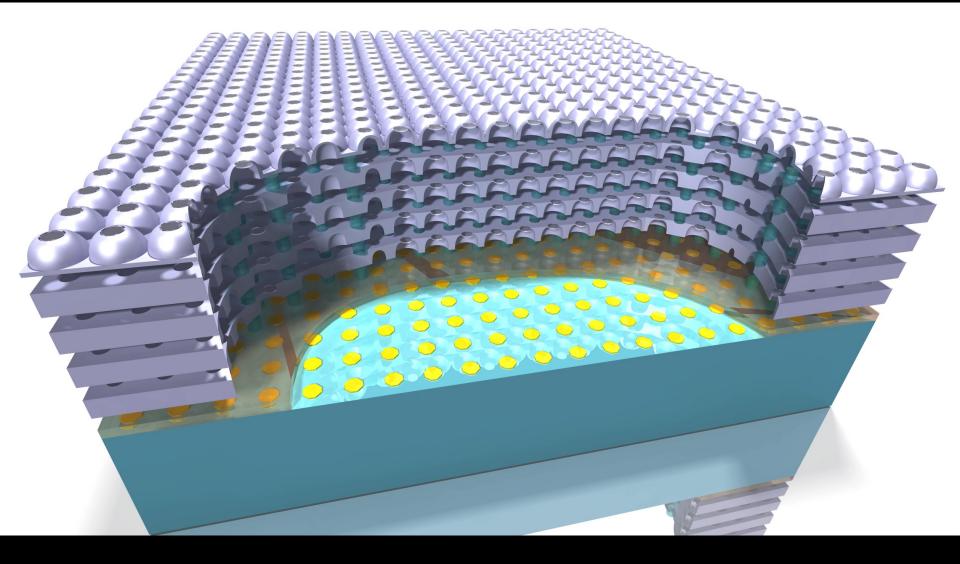




Reinforcement bars required: creates dead regions

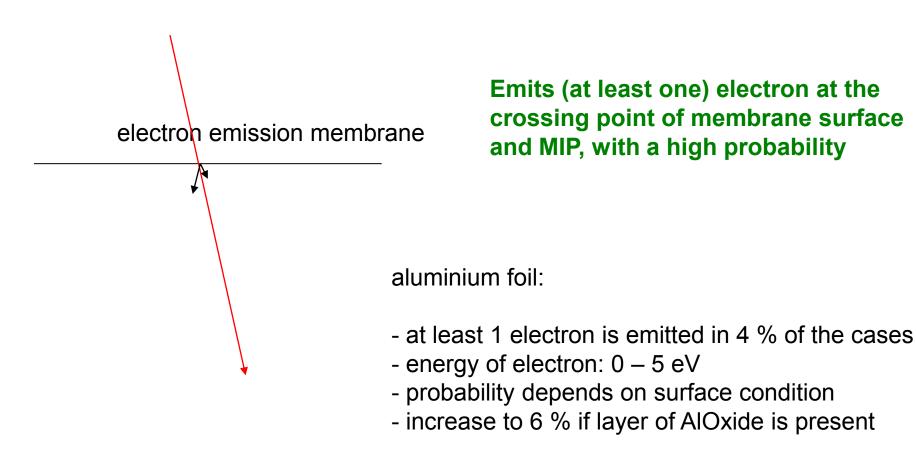
Problematic for 1st transmission dynode





For tracking of fast charged particles (MIPS):

Replace photocathode by **Electron Emission Membrane**



Possible improvements in electron emission efficiency:

- low work function (CsI, bi-alkali, CVDiamond)
- surface treatment: CVDiamond, nanotubes, fractals
- Extracting electric field

Try to develop membrane with 50 – 95 % efficiency!

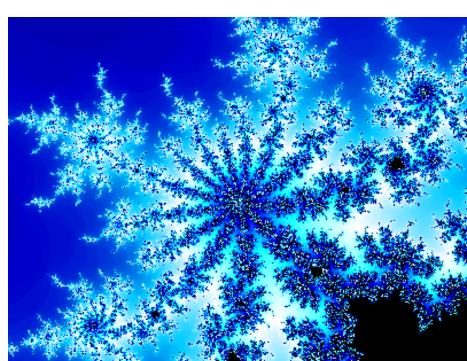
↓ MIP

Skin effect: only skin of ~ 50 nm participates in EE.

Rise of EE efficiency by surface enlargement: meandering, modulating, roughening

 \sim

2nd order modulation, 3rd order.....fractals! Extracting E-field: constant at surface



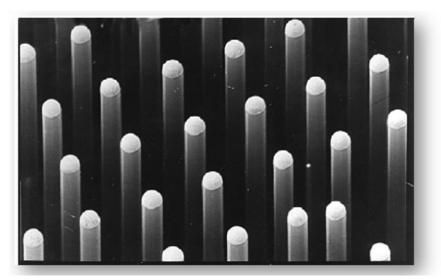
Work function

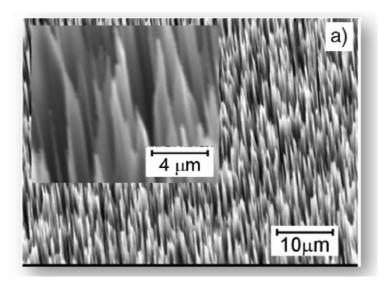
Interesting: - photo cathodes of PMs (bi-alkali etc) - coating of dynodes of PMs - Eff Alu, Cu: ~ 4 %

- Eff ceramics (Diamond, CsI, Si₃N₄): 10 - 20 %?

Exctracting electric field (close to cold electron emission)

- nano grass



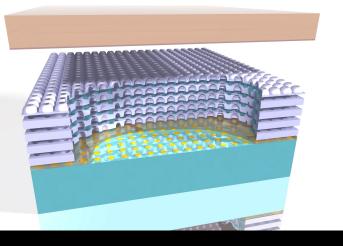


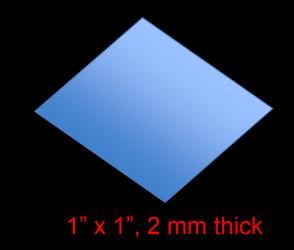
Conclusions

MultiPix MEMS made vacuum electron multiplier integrated on pixel chip

MultiPix + 'classical' photo cathode Timed Photon Counter TiPC Tipsy

MultiPix + Electron Emission Membrane MIP tracking detector



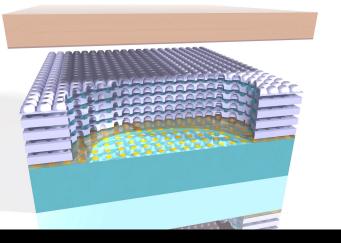


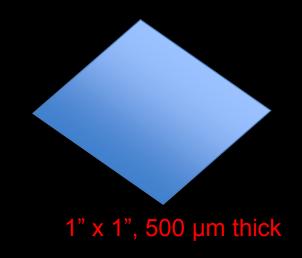
Timed Photon Counter TiPC Tipsy

- good quantum efficiency
- ultra fast, ps time resolution
- low noise
- little dark current, no bias current
- radiation hard
- perfect linear

- flat, thin & light
- 2D position resolution $\sim 10 \ \mu m$
- potentially cheap.....!
- little radioactive
- can stand B fields

Potentially outperforms APDs, G-APDs, SPADs, dSiPMs, QUPIDs Consumer application: 3D pictures by measurement Time-of-Flight.....!





MIP Tracking detector

- moderate track efficiency 50 90 %
- ultra fast, ps time resolution
- low noise
- little dark current, no bias current
- radiation hard

- flat, thin & light
- 2D position resolution ~ 10 μm
- potentially cheap.....!
- can stand B fields
- no 3D track vector info (GridPix)

Outperforms Si trackers in terms of time resolution

- high rate experiments
- BX timing: ILC/CLIC experiments